

Simulation of Charge Collection in Microstrip Detectors

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Simulation Conception

- Calculation of electric, resp. weighting field, in MAXWELL 2D simulation software, data export on a grid and conversion into hbook format
- Monte Carlo simulation
 - generation of e-h pairs
 - by a laserbeam incident at a certain angle
 - by a minimum ionizing particle (180 GeV/c pion) (Geant3)
 - e-h pairs propagation in a silicon bulk
(Many thanks belong to N.Mazziotta, F.Loparco INFN Bari, see NIMA 533 (2004))
 - calculation of the current induced at time t by a moving carrier (e,h) on the electrodes (strips) via Shockley-Ramo theorem
 - results (histograms, graphs or ntuples) saved in hbook format (converted into ROOT format)
- Crosstalk simulation, further processing (ROOT)

Simulation Parameters – barrel det.

detector depth = 285 μm

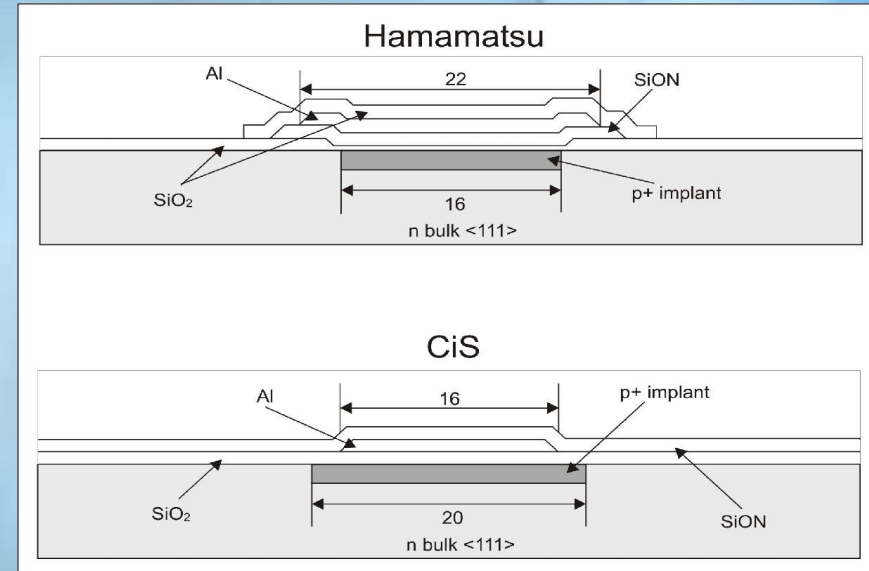
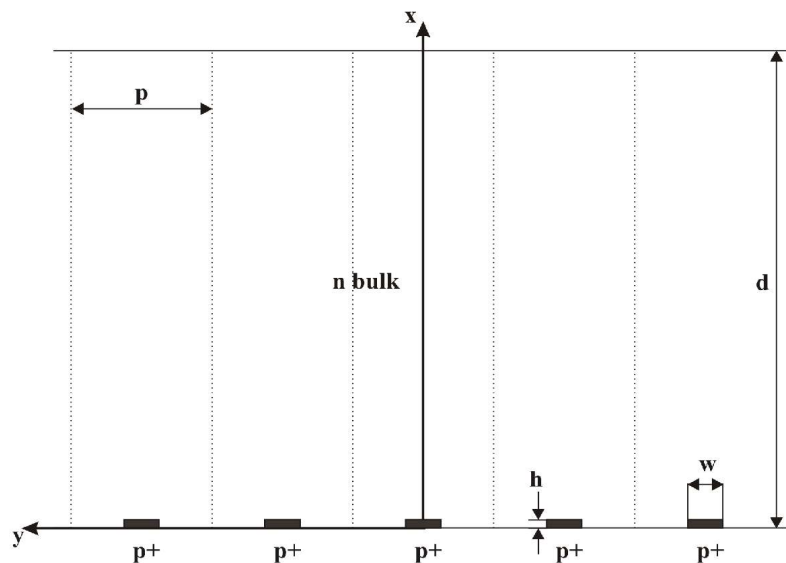
pitch = 80 μm

p⁺ width = 16 μm

p⁺ height $\approx 1 - 1.5 \mu\text{m}$

Al width = 22 μm

Al height $\approx 1 \mu\text{m}$



$$N_{\text{donors}} = 10^{12} \text{ cm}^{-3}$$

$$N_{\text{acceptors}} = 3 \cdot 10^{19} \text{ cm}^{-3}$$

$$C_{\text{interstrip}} = 6 \text{ pF}$$

$$C_{\text{backplane}} = 1.77 \text{ pF}$$

$$C_{\text{coupling}} = 120 \text{ pF}$$

$$\text{ENC} \approx 1500 \text{ e} \approx 0.24 \text{ fC}$$

$$\text{bias voltage} = 150 \text{ V}$$

Simulation - electric field

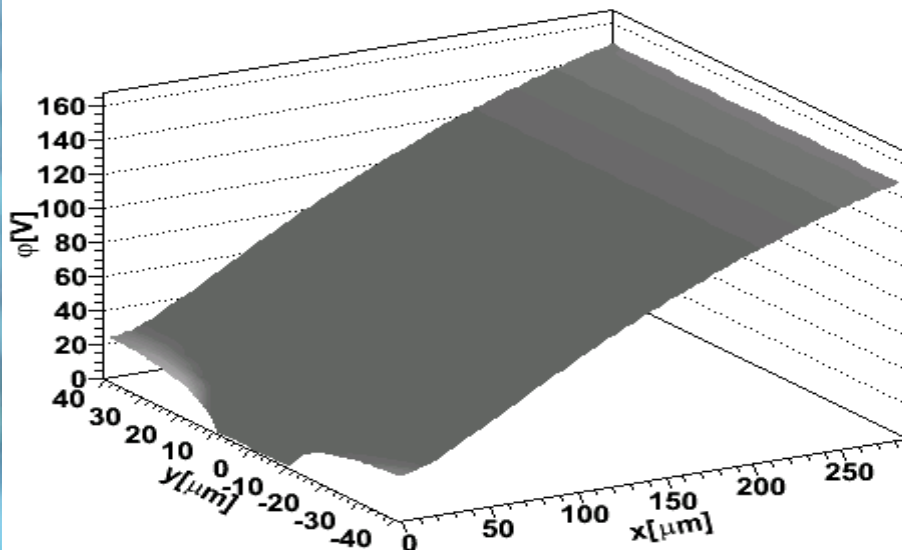
Calculation of electric (resp. weighting field) - realized by dividing the detector volume into elementary cells and solving Poisson's equation with following boundary conditions:

$$\varphi(x=d)=150\text{ V}$$

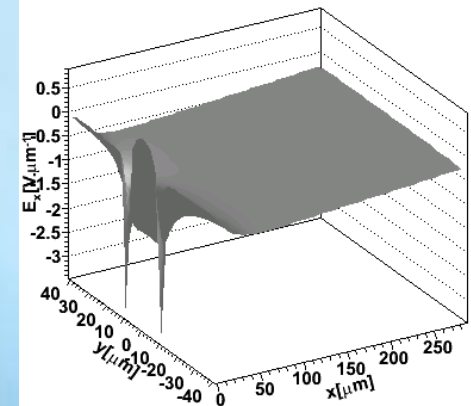
$$\varphi(y=-p/2)=\varphi(y=+p/2)$$

$$\varphi(x=0, -w/2 \leq y \leq +w/2) = 0\text{ V}$$

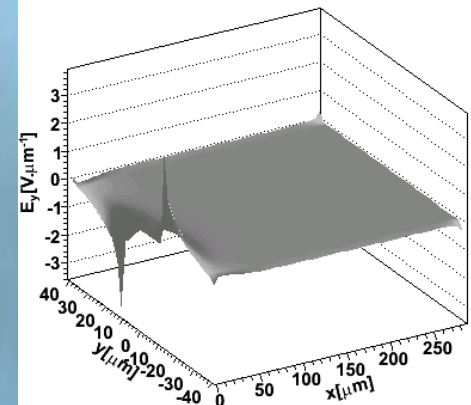
Electric potential in an elementary cell



E_x in an elementary cell



E_y in an elementary cell



Simulation – e-h generation (Geant3)

- Energy loss distr. – Landau distribution x PAI model
 - for typical thickness ($\approx 300 \mu\text{m}$) of silicon wafers the Landau distribution (automatically set in Geant 3) is not adequate for description of energy loss distribution
 - PhotoAbsorption Ionization model (PAI model) is correct
 - automatic choice of model is connected with the significance parameter: $\kappa = \xi / T_{max}$ (Landau corresponds to $\kappa \leq 0.01$ for $\xi \gg I$)
 - the validity of Landau distribution is strongly dependent on: particle energy, Z_{med} , A_{med} , wafer thickness, mean ionization potential I
- 2 models of passage of ionizing particles (180 GeV/c pions) through the detector volume used:
 1. fast simulation without δ -electrons – generation of e-h pairs uniformly along the track, energy loss generated according to the Geant 3 energy loss distribution (PAI model, 1 e-h pair ≈ 3.65 eV)
 2. full simulation with δ -electrons, PAI model, STEMAX = $5 \mu\text{m}$

Simulation – e-h generation (Geant3)

- energy loss distributions of 8 GeV/c pions in 290 μm Si (PAI model \times Landau)

- **PAI model** (black)

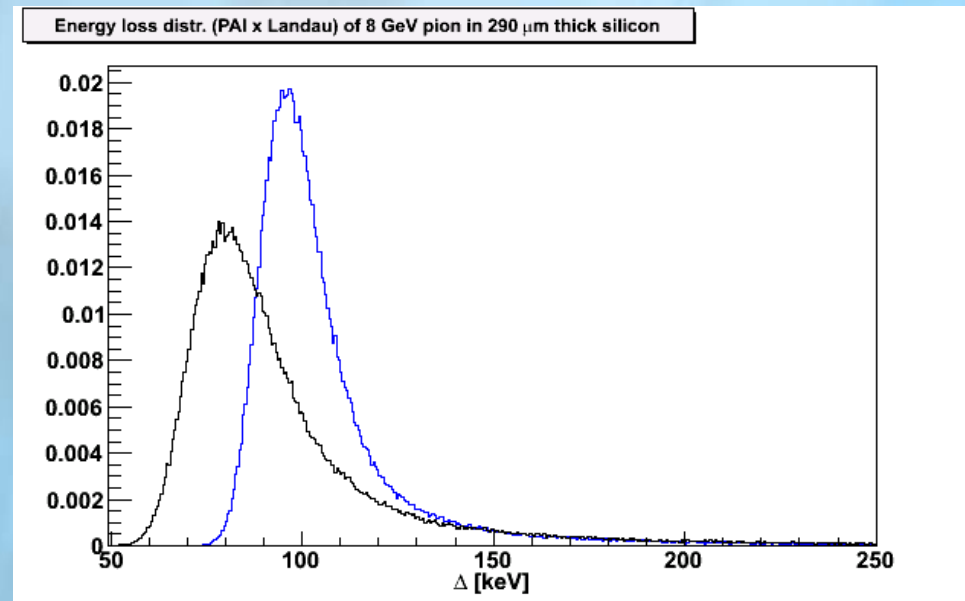
- MPV $\Delta E = (79 \pm 1)$ keV
- width = (29 ± 1) keV

- **Landau** (blue)

- MPV $\Delta E = (96 \pm 1)$ keV
- width = (20 ± 1) keV

- **Experimental values**

- MPV $\Delta E = (79.43)$ keV
- width = (29.24) keV



Simulation – e-h pairs propagation

- the drift of e-h pairs in electric field is described by:

$$\vec{v}(\vec{r}(t)) = \mu \cdot \vec{E}(\vec{r})$$

- the mobility is strongly dependent on electric field and temperature:

$$\mu = \frac{v_m / E_c}{(1 + E / E_c^\beta)^{1/\beta}}$$

- ODF solved numerically using Runge-Kutta method
 - with optimal space accuracy set as: $\varepsilon = 5 \mu\text{m}$
 - with integration step calculated as: $\delta t = \varepsilon / |\vec{v}(\vec{r}(t))|$
- the pairs are diffused during the motion by multiple collisions
 - the new distribution after time t is described by Gaussian law:

$$dN = \frac{N}{\sqrt{4\pi Dt(\vec{r})}} \exp\left(-\frac{\vec{r}^2}{4Dt(\vec{r})}\right) d\vec{r}$$

- the total simulation step: $\delta \vec{r} = \delta \vec{r}_{\text{drift}} + \delta \vec{r}_{\text{diffusion}}$

Simulation – weighting field

- the current induced at time t on the k^{th} electrode by a moving carrier can be evaluated using Shockley-Ramo theorem:

$$i_k(t) = -q \vec{v} \cdot \vec{E}_{wk}$$

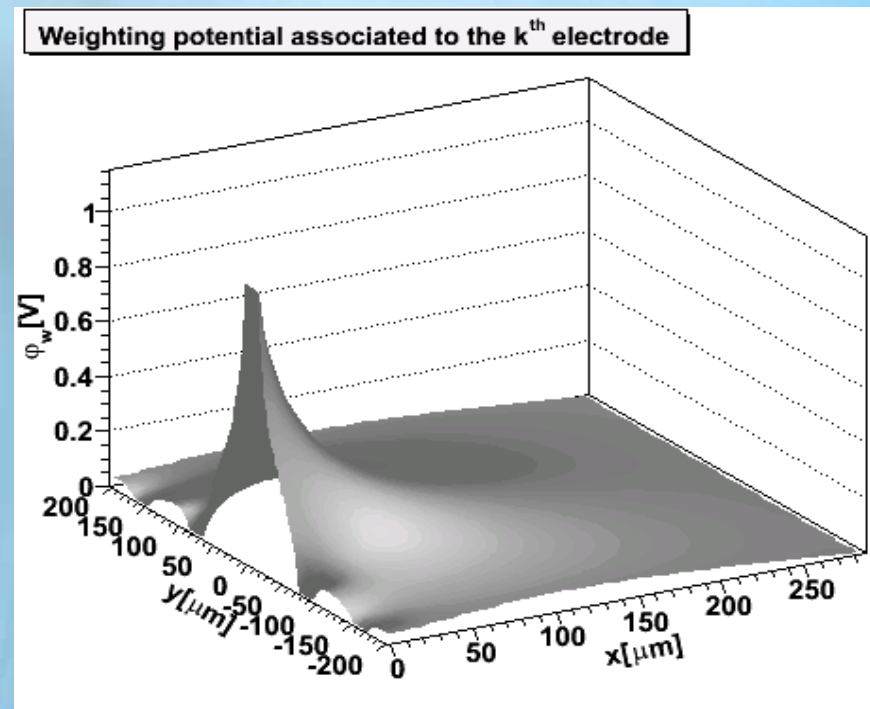
- \vec{E}_{wk} is the weighting field associated to k^{th} electrode

- describes the geometrical coupling between a carrier and the electrode
- obtained as a solution of Laplace equation with boundary conditions:

$$\varphi_{wk}(x=0, y=kp) = 1 \quad k=0, \pm 1, \pm 2$$

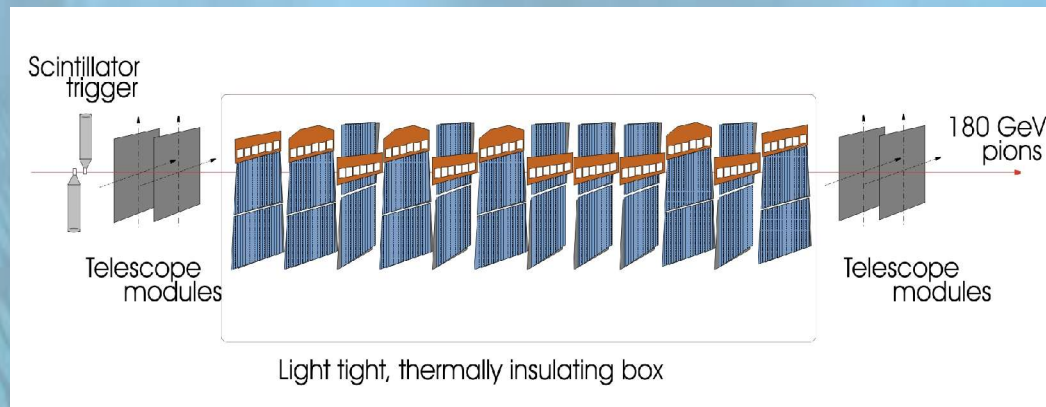
$$\varphi_{wi}(x=0, y=ip) = 0 \quad i \neq k$$

$$\varphi_w(x=d) = 0$$



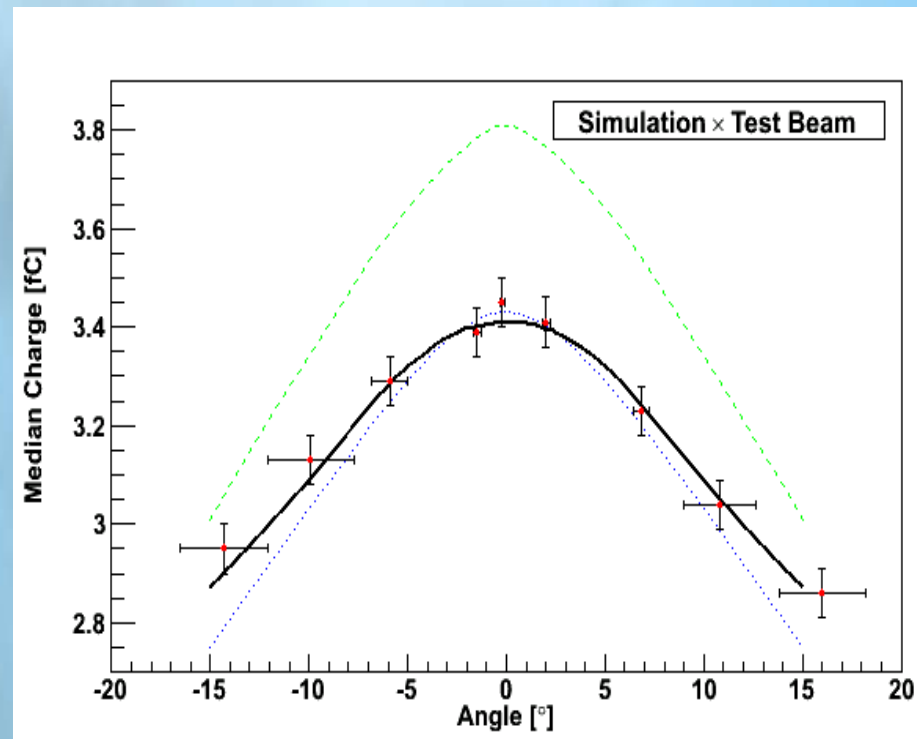
SCT Beam Tests Simulations

- simulation of SCT detector response to a beam of 180 GeV/c pions (ATLAS CERN 2000–2004), comparison with the real experimental data and verification of simulation reliability:
 - for Hamamatsu barrel detector:
 - ENC 1500 e \approx 0.24 fC
 - multiple scattering resolution $\sigma = 6 \mu\text{m}$
 - telescope resolution $\sigma = 5 \mu\text{m}$
 - discriminator threshold: 1 fC (detector efficiency higher than 99 %)
 - study of the influence of: δ -electrons, crosstalk (2 x 4.7 %), diffusion and weighting field



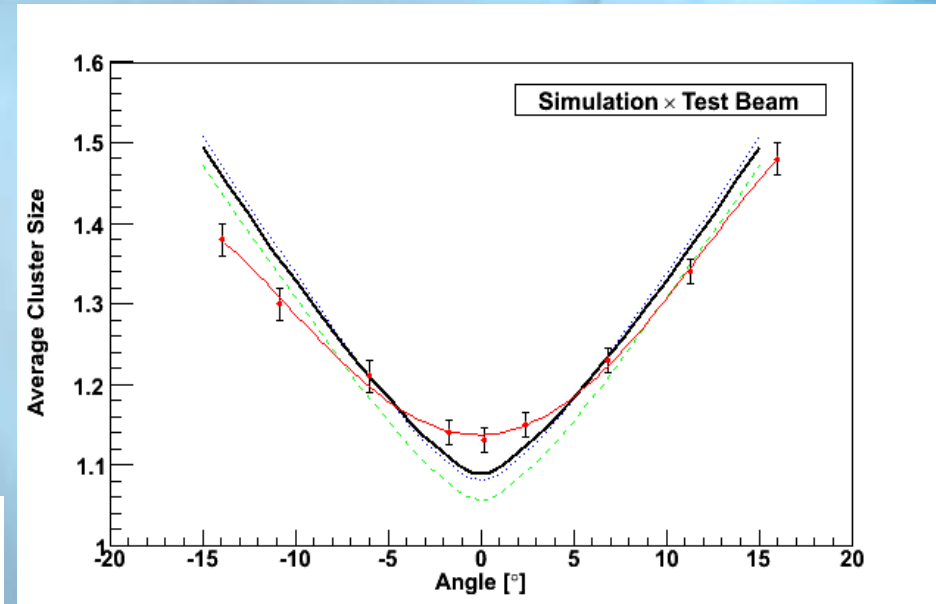
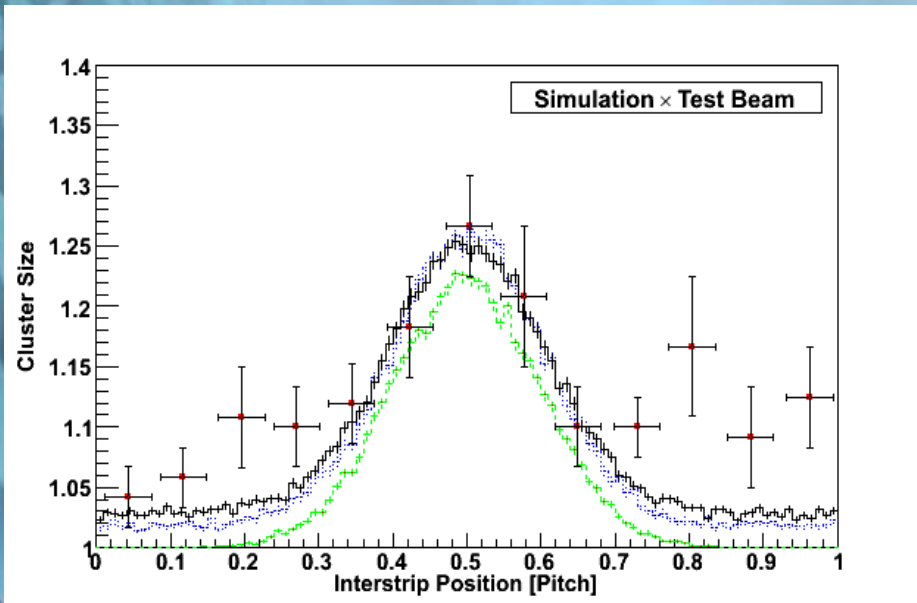
Beam Tests – median charge

- median charge versus incidence angle
- **2 mutually opposite effects:** path length $\approx 1/\cos(\alpha)$ **x** charge sharing effect
- **simulation:**
 - **green:** weighting field effect and diffusion
 - **blue:** including crosstalk
 - **black:** together with δ -electrons
- **for zero angle:**
 - deposited charge (3.91 ± 0.02) fC
 - **experiment:** (3.5 ± 0.1) fC
 - **simulation:** (3.41 ± 0.04) fC



Beam Tests – cluster size

- **cluster size** = the number of strips that collect the charge when a particle crosses the detector volume
- **2 types of measurements** (dependent on):
 - angle of incidence
 - interstrip position

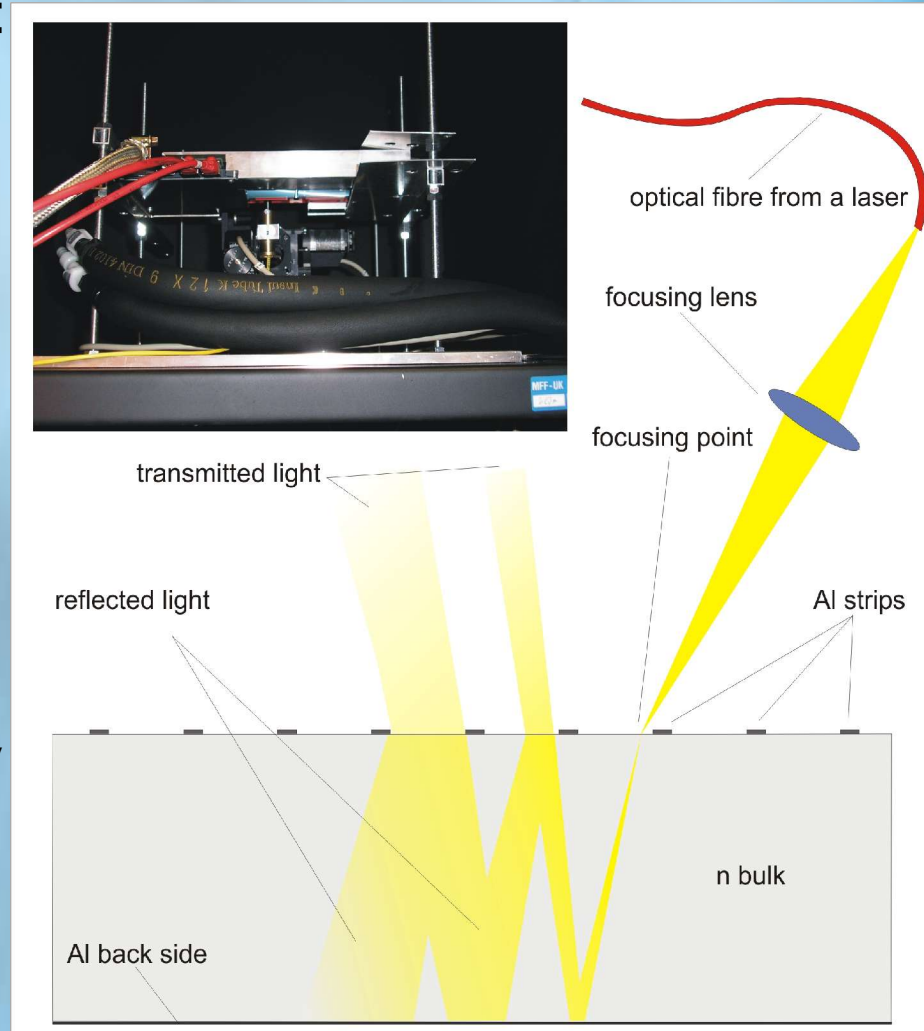


- **simulation:**
 - **green:** weighting field effect and diffusion
 - **blue:** including crosstalk
 - **black:** together with δ -electrons

Simulation – laser beam

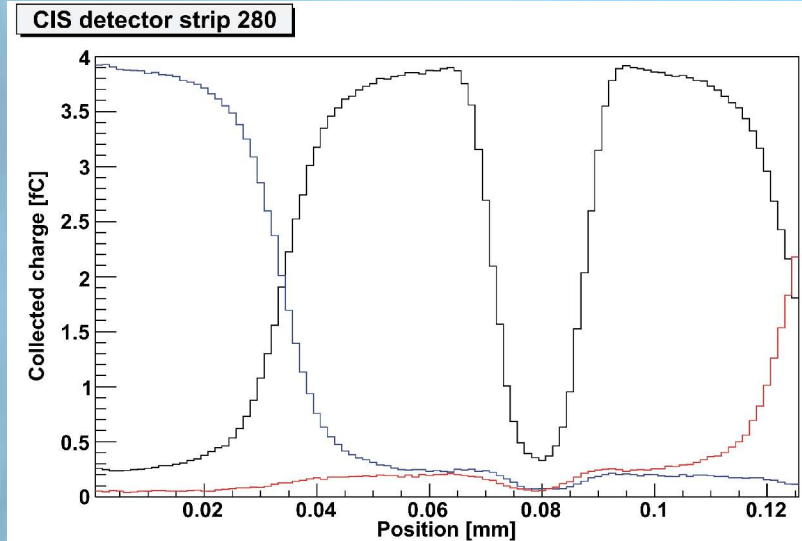
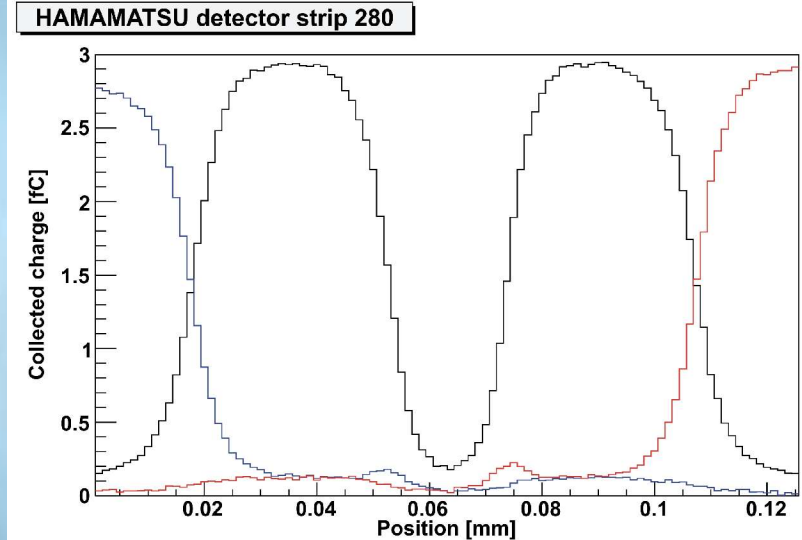
Geometrical model of laser beam:

- gaussian profile in plane perpendicular to the direction of motion $\sigma = 2.8 \mu\text{m}$
- beam divergency $\approx \pm 1^\circ$ in direction of motion
- exponential attenuation of the beam (until intensity decreases below $\sim 3\%$)
- reflection on metal layers $\approx 90\%$ and interface between air and Si $\approx 32\%$
- each photon generates 1 e-h pair
- equivalent generated charge $4 \text{ fC} \approx \text{MIP}$
- **wavelength:** $\lambda = 1060 \text{ nm}$, $E_{\text{ph}} = 1.17 \text{ eV}$
- **attenuation length:** $\lambda_{\text{att}} = 894.2 \mu\text{m}$
- **refraction index:** $n = 3.554$



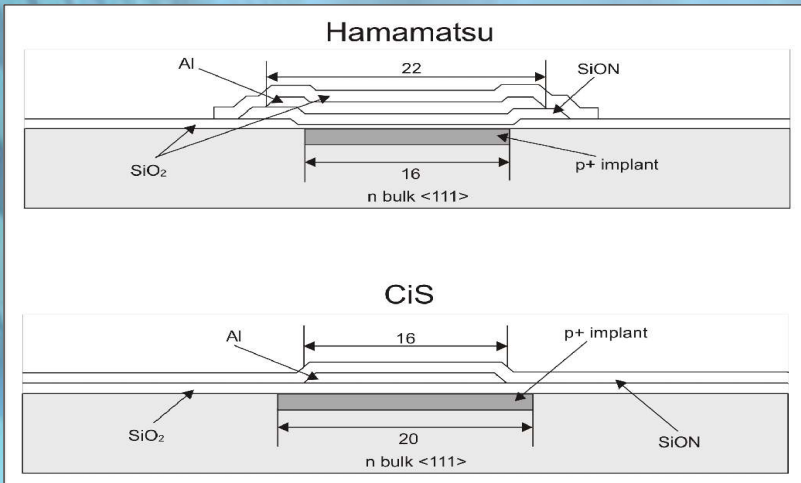
Experimental results – pitch

- detectors with 2 different technologies (Hamamatsu and CiS) measured
- end-cap modules measured
 - $\text{pitch}_{\text{Ham}} = 90.0 \pm 0.5 \mu\text{m}$
 - $\text{pitch}_{\text{CiS}} = 90.0 \pm 0.5 \mu\text{m}$

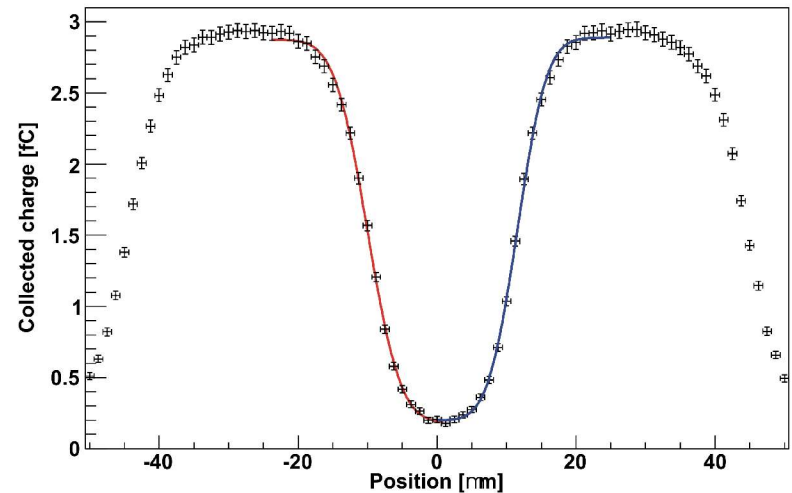


Experimental results – parameters

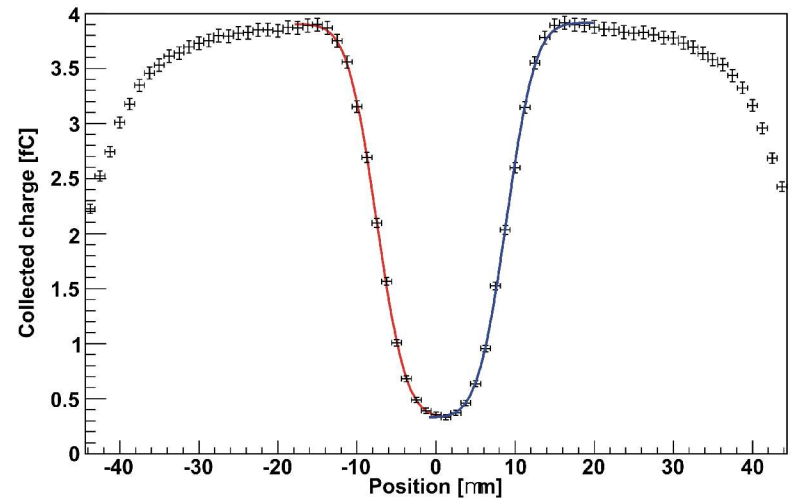
- detectors with 2 different technologies (Hamamatsu and CiS) measured
- fit with an error function and a complementary error function
 - Al strip width_{Ham} = $21.6 \pm 0.5 \mu\text{m}$
 - Al strip width_{CiS} = $16.1 \pm 0.5 \mu\text{m}$
 - $\sigma_{\text{beam Ham}} = 3.55 \pm 0.10 \mu\text{m}$
 - $\sigma_{\text{beam CiS}} = 2.86 \pm 0.07 \mu\text{m}$



HAMAMATSU detector strip 280

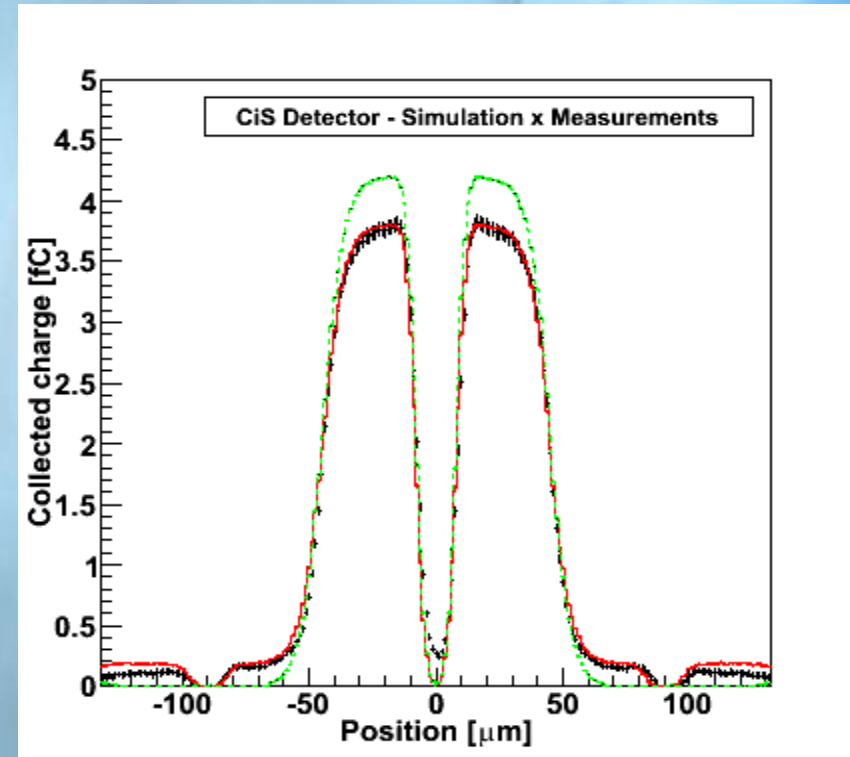
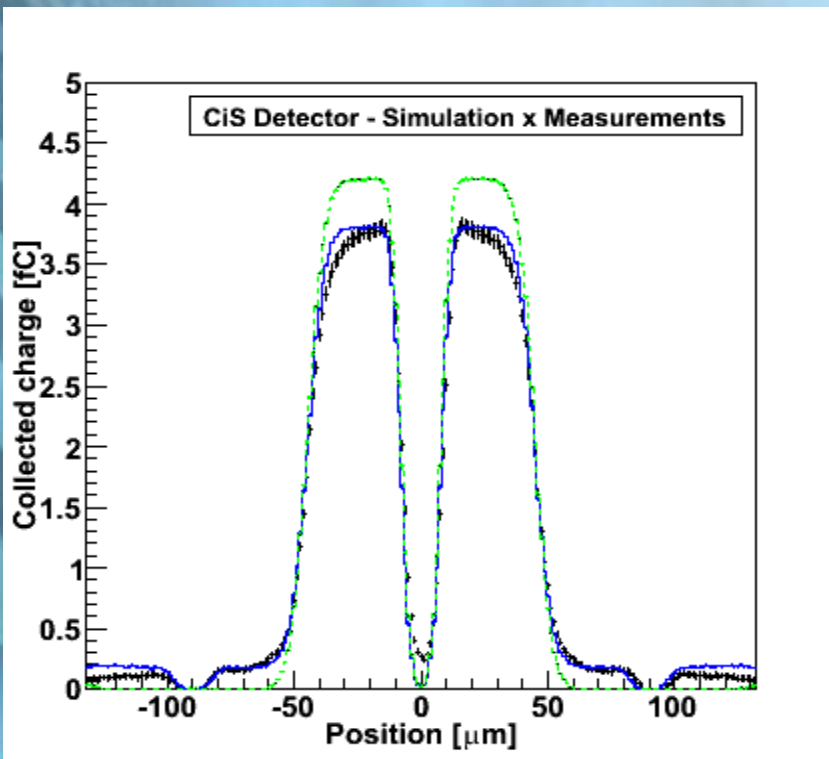


CiS detector strip 280



Comparison with Simulation – CiS

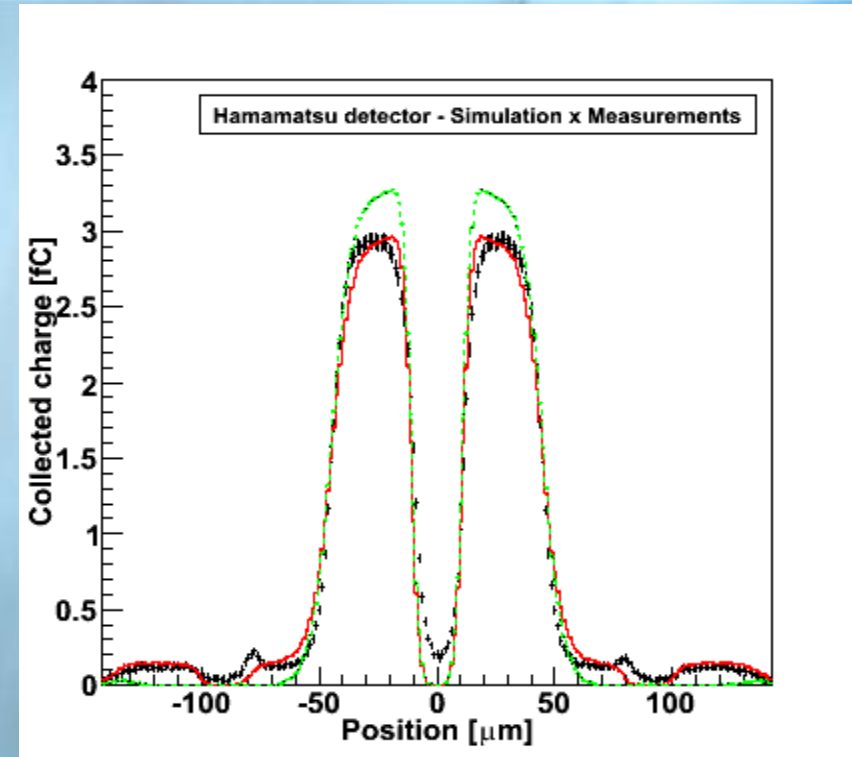
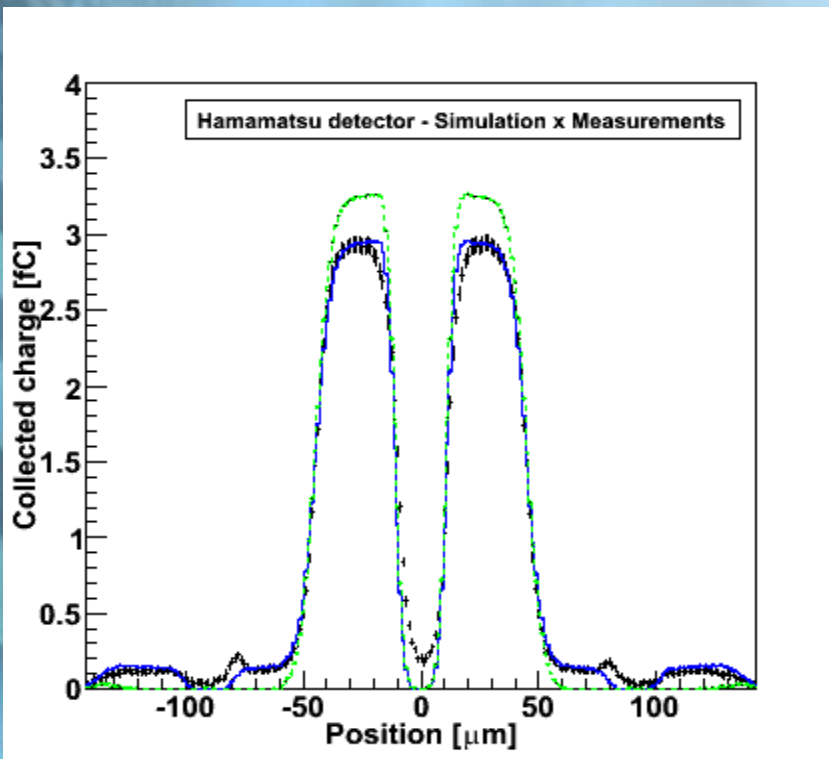
- $\sigma_{\text{beam CiS}} = 2.8 \mu\text{m}$
- divergency_{beam CiS} = $\pm 0.5^\circ$ (blue)
- divergency_{beam CiS} = $\pm 1.25^\circ$ (red)
- simulation without crosstalk (green)



- **experiment:** (discrepancy in strip region)
 - 5 % of dep. signal ≈ 0.2 fC gets into the surface layer in strip area (protect. layer behaves as a waveguide)
 - 1 % dep. signal ≈ 0.04 fC “hallo” effect

Comparison with Simulation – Ham

- $\sigma_{\text{beam Ham}} = 2.8 \mu\text{m}$
- divergency_{beam Ham} = $\pm 0.5^\circ$ (blue)
- divergency_{beam Ham} = $\pm 1.25^\circ$ (red)
- simulation without crosstalk (green)



- **experiment:** increase of signal at neighbouring strip ≈ 0.1 fC can be explained by getting of optical signal into the “waveguide” at the central region and diverting back at neighbouring strips

Conclusion

- Development of 2D Monte Carlo simulation of charge collection in microstrip detectors
- Implementation of simulation into Geant 3 framework
- Correctness verification on real experimental beam tests data (measured in CERN)
- Interpretation of physical results
 - study of dependence of detector response to individual physical results: δ -electrons, crosstalk, diffusion and weighting field
- Simulation of detector response to a laser beam
 - interpretation of experimental results based on comparison with the simulations
 - verification of geometrical model of laser behaviour in a strip detector
 - extraction of basic parameters of laser and detector from simulation and measurements
- www-ucjf.troja.mff.cuni.cz/diploma_theses/drasal_dipl.pdf